

III. CLAIM AMENDMENTS

1. (currently amended) A substrate processing apparatus having a station for loading and unloading substrates from the apparatus, the station comprising:

an aperture closure for sealing a loading and unloading aperture of the station;

apparatus for removing a door of a substrate magazine and thus opening the substrate magazine, and for operating the aperture closure to open the aperture; and

an elevator for precisely positioning the open substrate magazine along a vertical axis within a usable range of motion; [.]

a buffer transport for positioning the substrate magazine along a second axis oriented in a second direction different from the vertical axis; and

a shuttle for transporting the substrate magazine along a third axis oriented in a third direction different from the vertical and second directions;

wherein the buffer transport is operative for moving the substrate magazine between a first position and a second position, wherein when in the first position the substrate magazine communicates with the aperture, and when in the second position the substrate magazine is offset from the first position and is buffered, and

wherein the first and second positions are horizontally coplanar.

2. (original) The substrate processing apparatus of claim 1, wherein the elevator operates such that a substrate within the open magazine is positioned substantially in a wafer transport plane, the substrate processing apparatus further comprising a transport apparatus for accessing the substrate in the wafer transport plane through the aperture.

3. (original) The substrate processing apparatus of claim 2, wherein the elevator includes a device for positioning the open substrate magazine such that substantially no vertical movement is required by the transport apparatus.

4. (currently amended) The substrate processing apparatus of claim 1, ~~further comprising a substrate buffer for temporary substrate storage wherein the first and second positions are substantially in a plane that includes the second axis.~~

5. (currently amended) The substrate processing apparatus of claim 1, wherein the ~~station further comprises at least one second position is in a peripheral area and the first position is in a central area.~~

6. (canceled)

7. (currently amended) The substrate processing apparatus of claim 5 [[6]], wherein the buffer transport is

operable to place the ~~one or more~~ magazine[[s]] in the ~~at least one~~ peripheral area and the central area.

8. (currently amended) The substrate processing apparatus of claim 7, wherein the elevator is operable to move the ~~one or more~~ magazine[[s]] placed in the central area.

9. (original) The substrate processing apparatus of claim 1, wherein the station further comprises a sensor for mapping vertical locations of the substrates.

10. (original) The substrate processing apparatus of claim 9, wherein the sensor is mounted to a frame of the station and is capable of mapping the vertical location while the elevator is precisely positioning the open substrate magazine along the vertical axis.

11. (original) The substrate processing apparatus of claim 9, wherein the sensor is rotatably mounted on a frame of the station such that upon removal of a door of the magazine, the sensor extends inside the magazine.

12. (canceled)

13. (original) The substrate processing apparatus of claim 1, wherein the station further comprises a mini-environment for interfacing the station to the substrate processing apparatus.

14. (currently amended) ~~The substrate processing apparatus of claim 9, wherein the A substrate processing~~

apparatus having a station for loading and unloading substrates from the apparatus, the station comprising:

an aperture closure for sealing a loading and unloading aperture of the station;

a fluidic magazine door drive for removing a door of a substrate magazine and thus opening the substrate magazine, and for operating the aperture closure to open the aperture; and

a sensor, for mapping vertical locations of the substrates, [[is]] mounted to the [[a]] magazine door drive of the station; [[.]]

wherein the fluidic magazine door drive further comprises an encoder for determining the vertical position of the sensor.

15. (currently amended) The substrate processing apparatus of claim 14, wherein the ~~magazine door drive is a fluidic drive. sensor is a through-beam sensor.~~

16. (original) The substrate processing apparatus of claim 14, wherein the magazine door drive is a pneumatic drive.

17. (currently amended) The substrate processing apparatus of claim 14, wherein the sensor is operable to

map the substrate locations while the fluidic magazine door
drive elevator is positioning the door of the open
substrate magazine along the vertical axis.

18. (canceled)

19. (currently amended) The substrate processing apparatus of claim 14 [[18]], wherein the substrate locations are determined by recording the magazine door
drive elevator vertical position information when the sensor detects an individual substrate.

20. (original) The substrate processing apparatus of claim 14, wherein the sensor is operable to map the substrate locations during an operation of the magazine door drive.

21. (canceled)

22. (currently amended) The substrate processing apparatus of claim 20 [[21]], wherein the substrate locations are determined by processing the magazine door drive position information when the sensor detects an individual substrate.

23. (canceled)

24. (currently amended) The substrate processing apparatus of claim 14 [[23]], further comprising a transport apparatus for accessing substrates in the substrate magazine through the loading and unloading aperture.

25. (currently amended) The substrate processing apparatus of claim 14 [[23]], further comprising a substrate buffer for temporary substrate storage.

26. (currently amended) The substrate processing apparatus of claim 14 [[23]], wherein the station further comprises at least one peripheral area and a central area.

27. (currently amended) The substrate processing apparatus of claim 14 [[23]], further comprising a buffer transport for positioning the substrate magazine in at least one peripheral area and the central area.

28. (currently amended) The substrate processing apparatus of claim 14 [[23]], wherein the station further comprises a mini-environment for interfacing the station to the substrate processing apparatus.

29. (canceled)

30. (canceled)

31. (canceled)

32. (canceled)

33. (canceled)

34. (canceled)

35. (canceled)

36. (canceled)